

REMARKS

Claims 1-4 are pending in this application. Claims 1 and 2 are withdrawn. By this Amendment, claim 3 is amended to further clarify the features therein. Claim 1 is amended to be consistent with claim 3 and should be rejoined when claim 3 is allowed. No new matter is added by this Amendment.

The Examiner is requested to consider the Supplemental Amendment along with the Amendment that was filed in the U.S. Patent and Trademark Office on March 1, 2006.

Applicant appreciates the courtesies shown to Applicant's representative by Examiners Dye and Dicus at the March 21, 2006 personal interview. Applicant's separate record of the substance of the interview is incorporated into the following remarks.

The amendment to claim 3 even further distinguishes claim 3 from U.S. Patent No. 6,165,587 (Nonaka). In particular, although the supporting section 23 or 24 of Nonaka may have an inverted "T" shape, Nonaka does not disclose that the supporting section 23 or 24 is made of a conductive material. Instead, in view of Nonaka's teaching at col. 3, lines 58-62, the supporting section 23 or 24 would be made of an insulating material such as silicon nitride or silicon oxide.

Accordingly, the patterned film, as recited in claim 3, does not correspond to Nonaka's supporting section 23 or 24. That is, Nonaka fails to disclose a patterned film made of a conductive material, the patterned film being disposed on the base layer and including a linear portion, wherein the linear portion has a first portion and a second portion, wherein the second portion is closer to the base layer than the first portion, and wherein the second portion touches the base layer, the second portion having a width greater than a width of a first portion, as recited in claim 3.

In view of the foregoing, claim 3 as well as claim 4 depending therefrom, are not anticipated by Nonaka or Kamijima.

It is respectfully submitted that this application is in condition for allowance.

Favorable reconsideration and prompt allowance of the pending claims are earnestly solicited.

Should the Examiner believe that anything further would be desirable in order to place this application in even better condition for allowance, the Examiner is invited to contact the undersigned at the telephone number set forth below.

Respectfully submitted,



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